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ATTORNEY DOCKET NO. CONFIRMATION NO. APPLICATION NO. FILING DATE FIRST NAMED INVENTOR 10/042,271 01/11/2002 Masato Yoshida 566.38683CX1 6050 **EXAMINER** 20457 7590 10/20/2004 ANTONELLI, TERRY, STOUT & KRAUS, LLP MCDONALD, SHANTESE L 1300 NORTH SEVENTEENTH STREET PAPER NUMBER **ART UNIT SUITE 1800** ARLINGTON, VA 22209-9889 3723

DATE MAILED: 10/20/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)	
	10/042,271	YOSHIDA ET AL.	
Office Action Summary	Examiner	Art Unit	
	Shantese L. McDonald	3723	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply			
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).			
Status			
 Responsive to communication(s) filed on <u>28 May 2004</u>. This action is FINAL. 2b) This action is non-final. Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i>, 1935 C.D. 11, 453 O.G. 213. 			
Disposition of Claims			
 4) Claim(s) 30-49 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 30,33,35-41,46,48 and 49 is/are rejected. 7) Claim(s) 31,32,34,42-45 and 47 is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement. 			
Application Papers			
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) accomplicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Example 11.	epted or b) objected to by the Eddrawing(s) be held in abeyance. See ion is required if the drawing(s) is obj	e 37 CFR 1.85(a). ected to. See 37 CFR 1.121(d).	
Priority under 35 U.S.C. § 119			
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 			
Attachment(s)			
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 7/22/04. A) Interview Summary (PTO-413) Paper No(s)/Mail Date Notice of Informal Patent Application (PTO-152) Other:			

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DETAILED ACTION

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claim 32 recites the limitation "said crystallite" in line 2. There is insufficient antecedent basis for this limitation in the claim.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 30,36-41,46,48 and 49 are rejected under 35 U.S.C. 102(b) as being anticipated by Sasaki et al.

Sasaki et al. teaches an abrasive comprising porous cerium oxide particles having a crystal grain boundary and having a maximum diameter of not larger than 3000nm, (col. 10, lines 53-55 and col. 5, line 66- col. 6, line 1). Sasaki et al. also teaches that the abrasive comprises water, (col. 14, line 26), and a dispersant, which is a polyacrylic acid type polymer, (col. 12, lines 24-39), and a method of polishing a semiconductor silicon substrate, (col 5, line 46).

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Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 33 and 35 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sasaki et al. in view of Bonneau et al.

Sasaki et al. teaches all the limitations of the claims except for the cerium oxide particles being porous and having a pore volume of from 0.02 to 0.05 cm3/g. Bonneau et al. teaches porous cerium oxide particles with a pore volume of form 0.02 to 0.05 cm3/g, (col. 2, lines 26-33). It would have been obvious to one having ordinary skill in the art at the time the invention was made, to provide the composition of Sasaki et al. with a porous cerium oxide, as taught by Bonneau et al., in order to enhance the polishing capabilities.

Allowable Subject Matter

Claim31, 34,42-45 and 47 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Homma et al. was cited to show another example of a polishing composition.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shantese L. McDonald whose telephone number is (703) 308-8722. The examiner can normally be reached on 8:00 a.m. - 4:30 p.m..

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Joseph Hail can be reached on (703) 308-2687. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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S.L.M. October 18, 2004

Joseph J. Hail, III Supervisory Patent Examiner Technology Center 3700